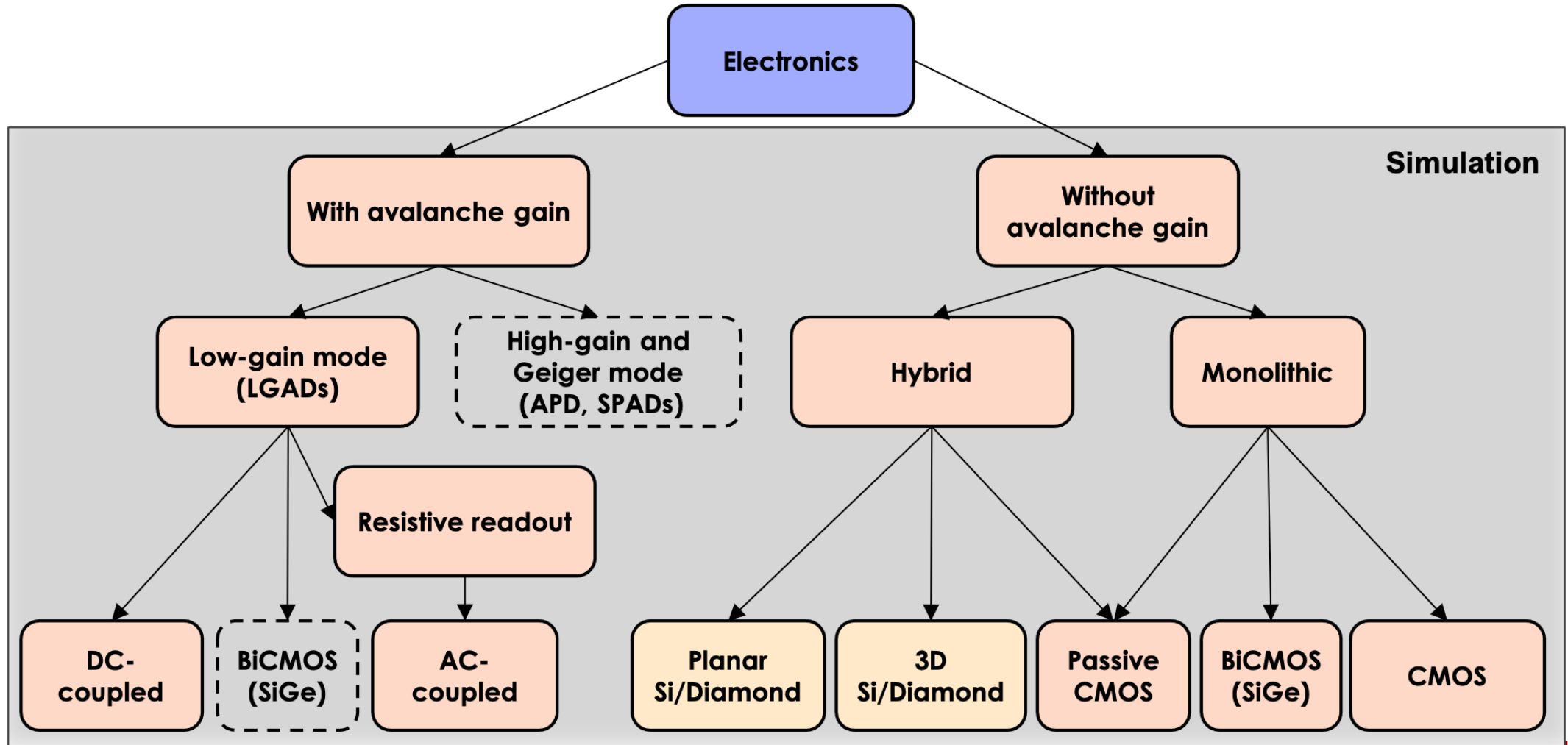


# Summary of the input section



# Status of the document

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Almost all sections have text, some bulleted and some extended.

This outline does not overlap directly with the talks

- Overview
- Summary of the future facilities requirements
- Silicon at extreme fluences
- Status and evolution of the simulation tools
- Sensors for 4D tracking
  - Sensors without internal gain (pros/cons)
  - Sensors with internal gain (pros/cons)
- **MAPS for particle tracking and high time resolution (still empty)**
  - Passive CMOS
- **Wide band-gap semiconductors (Diamond and more)**
  - Diamond
- The future of interconnections
- Summary of panel about industrialization
- Summary of panel about facilities

# Overview - I

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## **Solid state sensors R&D is broadly dominated by silicon**

- **Requests for future facilities are both reasonable and absolutely challenging**
  - Important point: there is a lot more than extreme fluence. Obviously FCC-hh fill a lot of phase space in R&D, but there is a lot more to do
- **Simulation needs to follow this path, with a specific focus on highly irradiated sensors**
- **R&D is moving away from standard planar silicon**
  - MAPS is filling its place
  - Hybrid systems maintain relevance in specialized features such as timing
  - Specialized sensors (such as 3D or diamond) are maintaining a phase space in specific applications
- **R&D: it is becoming very costly. Presently is organized in:**
  - Blue sky (RD50 from project/experiments, European money, not a sure stream)
  - Experiment driven, often is too late to do blue sky
    - ==> needs to look at a different way

# Overview - II

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- **Very important R&D in interconnections**
  - 3D stacking essential for both MAPS and hybrids
  - future facilities requires more compact and more reliable packaging.
- **Large area/sensors producers: dependance on a single producer should be addressed**
  - MAPS is a way to get away from it, important to push passive CMOS R&D
  - A focused industrial policy is another  
==> aka magnet R&D led by CERN
- **Facilities:**
  - Very difficult to handle irradiated sensors, we are not ready to handle, ship, and test them
  - Charge hadron facilities cannot irradiate at  $1E17$  n/cm<sup>2</sup>. Need to plan for it
  - Beamtest are a luxury, we need to actively support them

# Cross issues to be worked out in the next days

**TF6 - Calorimetry:** Large area sensors for calorimetry not in TF3. Silicon timing not directly addressed

**TF7- Electronics:** not in TF3. High timing is a common problem, not a sensors' or front-ends'

**TF8 – Integration:** hybridization, 3D integration is present

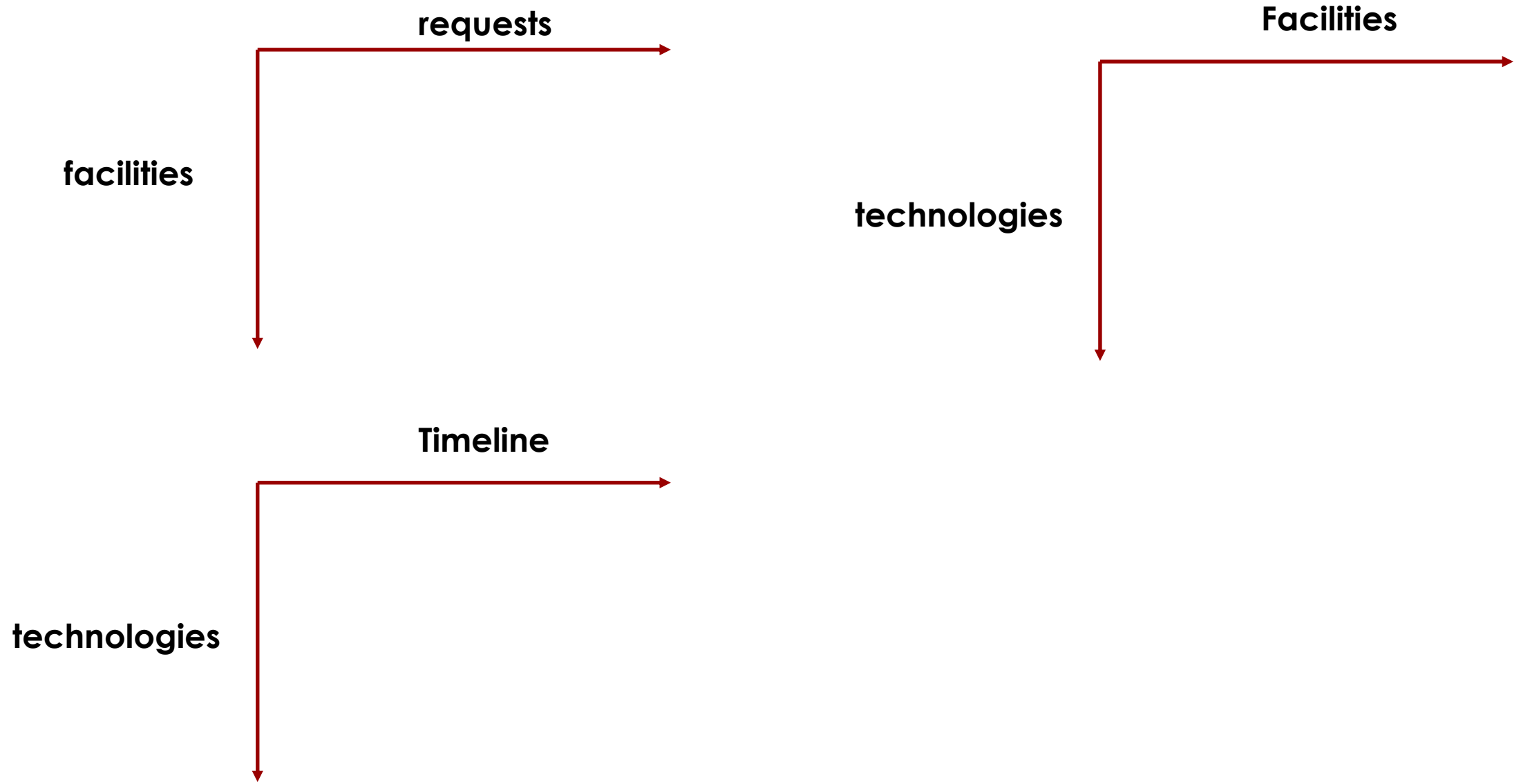
**TF0 – Training:** formal recognition is key. We need a patent of “detector guru”

The brand “CERN” is excellent, a “CERN expert detector patent” would be great to have. I wish I had it..

No problem in finding jobs outside academia

# Summaries: how many and what format

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# Problem in showing summary

The document begins with a summary. It is difficult to combine clarity and precision

This table has facilities vs technology

- Contains a lot of info
- took a long time to fill
- Impossible to see
- The numbers are important

This is a practical problem: how do we display it?

	Timescale	$\alpha_x$ ( $\mu\text{m}$ )	Pitch ( $\mu\text{m}$ )	X/Y <sub>0</sub> (%) / layer	Integration Time	Time Resolution	Rates	Temperature	Power Consumption	NIEL (1 MeV neq/cm <sup>2</sup> )	TID (Mrad)	Sensor size	Detector area (m <sup>2</sup> )	Technology Options and R&D
Panda (Fair/GSI)	2025	50	200?	0.1	100ns???	10 ns	10 MHz/cm <sup>2</sup>			1x10E14	10 Mrad		O(10)?	Hybrid pixels and strips 100um thick. Continuous readout: monolithic pixel detectors with a frame-wise readout which allows high spatial resolution and a low radiation length but with only a moderate time resolution.
CBM (Fair/GSI)	2025	5	30	0.1	5 $\mu\text{s}$	0.1 - 5 $\mu\text{s}$	70 MHz/cm <sup>2</sup>		60 mW/cm <sup>2</sup>	3x10E13	1	Stitching	4	Technologies under exploration: 180 nm TI (modified). 65 nm TI. Stitching.
NA62	2025		300	0.3 - 0.5		$\leq 50$ ps	800 MHz/cm <sup>2</sup>			2.3x10E15	100			silicon/3d/LGADs 28nm ASIC
ALICE inner layer r = 18 - 5 mm	2025-27 (L33) - 2031 (L54)	3	$\leq 25 - 10$	0.05	5 $\mu\text{s} - 0.1$ $\mu\text{s}$	1 $\mu\text{s} - 25$ ns	6 - 100 MHz/cm <sup>2</sup>		20 mW/cm <sup>2</sup>	10 <sup>11</sup> - 10 <sup>14</sup> (year <sup>-1</sup> )	3 - 10	12" - 28 x 10 cm <sup>2</sup>		
Belle-II	2030	10	30	0.1%*	25 ns total integration time		100 MHz/cm <sup>2</sup>		$\leq 200$ mW/cm <sup>2</sup>	10E14	100			Fast, high granularity, low mass replacement for current VXD: study of depleted CMOS MAPS; SOI sensors; thin strips. Timing layers: Possible use as TOF to improve PID performance
LHCb	2031 (L54)	10	55	1%	25ns	$\leq 50$ ps	**250 Gbps/cm <sup>2</sup> = 5 GHz/cm <sup>2</sup> for 50 bit words			6x10 <sup>14</sup> (r = 5 mm)	1 Grad?		Velo -> O (0.1) UT -> O(10)	Hybrid pixel detector with thin, 3D, or LGAD sensors.
ATLAS-CMS	2031 (L54) - 2035 (L55)	10	$\leq 50$	5% or less total	25 ns	$\leq 50$ ps	3 GHz/cm <sup>2</sup>			2.5x10E16	1 Grad		O(100)	Large size, ultrathin CMOS in deeper node (65 nm, standard, depleted); Thin hybrid planar/3D pixel sensor; 3D integration; radiation hard LGAD, Sensor: MAPS with < 20um pitch. LGADs or LAPPD for TOF.
EC	2031	$\leq 5$	20		25-35 ps		500MHz			1E10 per year			O(100)?	
ILC	2035	3	$\leq 25$	$\leq 0.2$	1-10 $\mu\text{s}$	5ns	O(10)MHz/cm <sup>2</sup>			1E11	0.1	8/12"	Vertex O(100) Calorimeter 2500	Lowest possible mass, highest possible resolution: ~ 3 $\mu\text{m}$ single point resolution < 0.2% X0 per layer -> Air flow cooling only Time resolution ~ 5 ns (or better) - interesting additional potential when pushing to the ps range Advances in both hybrid and monolithic technologies needed - fine-pitch bump bonding, speed
CLIC	3035	vertex tracker 7um	$\leq 25$	$\leq 0.2$	1-10 $\mu\text{s}$	5 ns	6 GHz/cm <sup>2</sup>	air cooled	50mW/cm <sup>2</sup> power pulsing	2x10E12 (6x10E10 /year)	300Gy/y		vertex (10) ? tracker 140	low-mass silicon pixel vertex detector surrounded by a low-mass silicon tracker, and highly-granular calorimetry. Vertex : monolithic CMOS technologies (SOI, HV-CMOS, HR-CMOS), CLIC-specific fully integrated designs. Calorimeter : silicon photomultipliers (SiPM)
FCC-ee	2040		$\leq 25$	inner 0.3-0.5% X0	1-10 $\mu\text{s}$	TOF 10ps	50 MHz/cm <sup>2</sup>	air cooled		2x10E14	1		O(100)	High spatial resolution (3-5 $\mu\text{m}$ ), timing (at least 20 ns for BX assignment), low material budget, low power consumption.
HE-LHC	2040				25 ns					2x10 <sup>17</sup>	6 Grad			
FCC-hh	2060	7	25 x 50	1	25 ns	$\leq 10$ ps	30 GHz/cm <sup>2</sup>			1x10E18	30 Grad		O(1000)	Explore the radiation tolerance limit of present technologies (3D detector, Diamond). Explore new materials: WBS, 2D material. Higher granularity pixels for calorimetry (TFs) - Need to explore innovative technologies
Muon-collider	>2035	5	$\leq 25$		20-30 ps defined by BC crossing time to minimize Beam Induced		50-100 MHz			1x10E12	0.1		Pixel sensor 0.5m <sup>2</sup> Strip/long pixels sensors: ~ 88 m <sup>2</sup> Barrel: ~ 69 m <sup>2</sup> Endcap: ~ 19 m <sup>2</sup>	Large size, thin CMOS in deep sub-micron techn. (28-65 nm, standard, depleted), DEPFET, thin pixelated LGAD (AC, resistive)
LHeC-FCC-eh-Perle	2024-2031	5-10	10-20	<5		25-35				low			41	CMOS Active Pixel Sensors for vertex and tracking layers: small pitch pixels, low-power, fast timing Low-cost, highly automated, module assembly, integration and test for large area trackers
SPS AMBER	2022 - 2026	23	80x81	0.02	25ns?	100ps	O(50-100) MHz/cm <sup>2</sup> abda			1.00E+14		1x1.7cm <sup>2</sup>		Pixelized Silicon Tracking Stations: MuPix10 chip. Scifi Tracker Stations : scintillating fibre are coupled to individual silicon photomultipliers (SiPMs).
SPS MuonE		5		0.1			700 MHz/cm <sup>2</sup>		5.4W 2S module			10x10cm <sup>2</sup>		Promising technology : DMAPS (Depleted Monolithic Pixel Sensors). Silicon sensors foreseen for the CMS HL-LHC Outer Tracker (OT) are 320 $\mu\text{m}$ thick sensors with n-in-p polarity produced by Hamamatsu Photonics (HPK).
SPS NA61/shine		3.5	18.4	0.1		100us			250 mW/cm <sup>2</sup>	1E13/y	0.3 /y	21.2 x 10.6 mm <sup>2</sup>		CMOS Monolithic Active Pixel Sensors (MAPS), MIMOSA
NA60+		$\leq 5$	10x10	0.1		200ns	100 MHz			1.00E+15		150x150 mm <sup>2</sup> with stitching		Sensor thickness: few tens of microns of silicon New large area sensors (based on stitching): No support under sensitive area -> material budget < 0.1% X0 -> MAPS TOWER 65nm
Existing in experiments														
Existing in demonstrators														
Not existing														

# One of goal of the next few days

Find a way to give the correct message clearly

		"Technical" Start Date of Facility (This means, where the dates are not known, the earliest technically feasible start date is indicated - such that detector R&D readiness is not the delaying factor)																											
		<2025		2025-2030		2030-2045		2035-2040		2040-2045					2045-2050		>2050												
Hybrid without intrinsic gain																													
Hybrid ...	Planar and 3D Si/Diamond																												
	Passive CMOS																												
	rad-hard																												
	low XO																												
	low power																												
	fast timing																												
	small pixel																												
	large array																												

- Must have to meet main physics goals
- Important to meet several physics goals
- Desirable to enhance physics reach